

NOTES

## Surface Characterization of Atactic Poly(methyl methacrylate) Aggregates Using Atomic Force Microscopy

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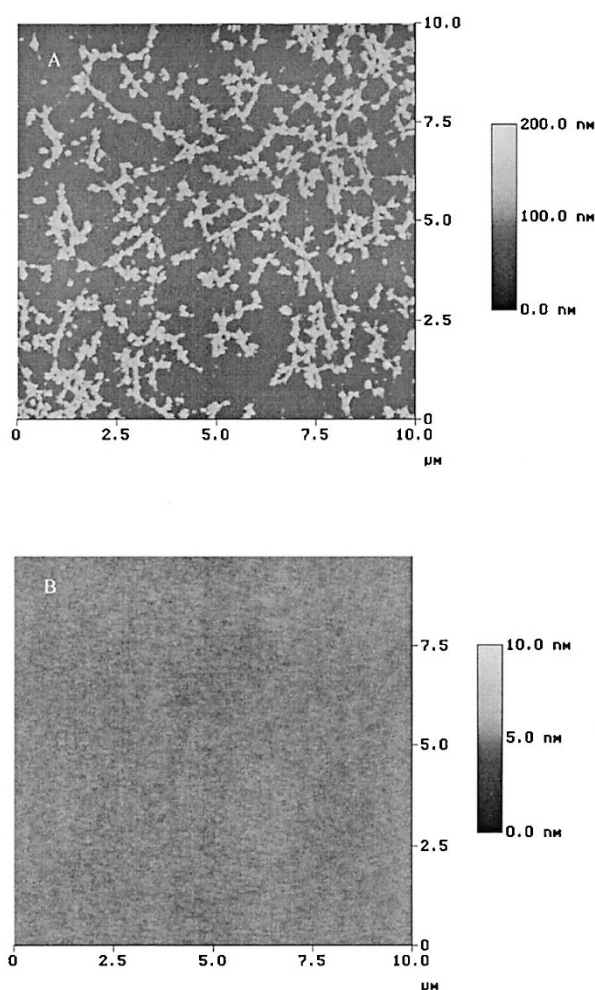
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Stereoregular poly(methyl methacrylate) (PMMA) recently has been attractive to many researchers. For the mixture of isotactic and syndiotactic poly(methyl methacrylate) (i-PMMA and s-PMMA) leads to formation of a stereocomplex which was revealed a double stranded helical structure in suitable solvents.<sup>1,2</sup> As for atactic poly(methyl methacrylate), Spevacek *et al.* and Borchard *et al.* proved that stereocomplex was able to form in its solution.<sup>3–5</sup> And a stereocomplex was also found in atactic PMMA film from strong complexing solvent acetone.<sup>6,7</sup> In this note, the effects of solvent and substrate on the patterning of a-PMMA aggregates were studied using by atomic force microscopy (AFM).

### EXPERIMENTAL

The average molecular weight of commercial a-PMMA was determined by means of gel permeation chromatography (PL-GP210),  $M_w = 43.3 \times 10^4$ ,  $M_w/M_n = 1.34$ . The tacticities of a-PMMA were determined by <sup>1</sup>H NMR, the proportions of iso, hetero, and syndio triads were 9%, 34%, and 57% respectively. Average segment lengths of mm and rr (monomer unit) of atactic PMMA are 1.53 and 4.35, respectively. The glass transition temperature ( $T_g = 112^\circ\text{C}$ ) was determined by DSC at  $10^\circ\text{C min}^{-1}$  rate. The solutions of atactic PMMA in acetone and chloroform solvents were prepared with the concentration of  $1 \text{ g L}^{-1}$ , and equilibrated for one week at room temperature.

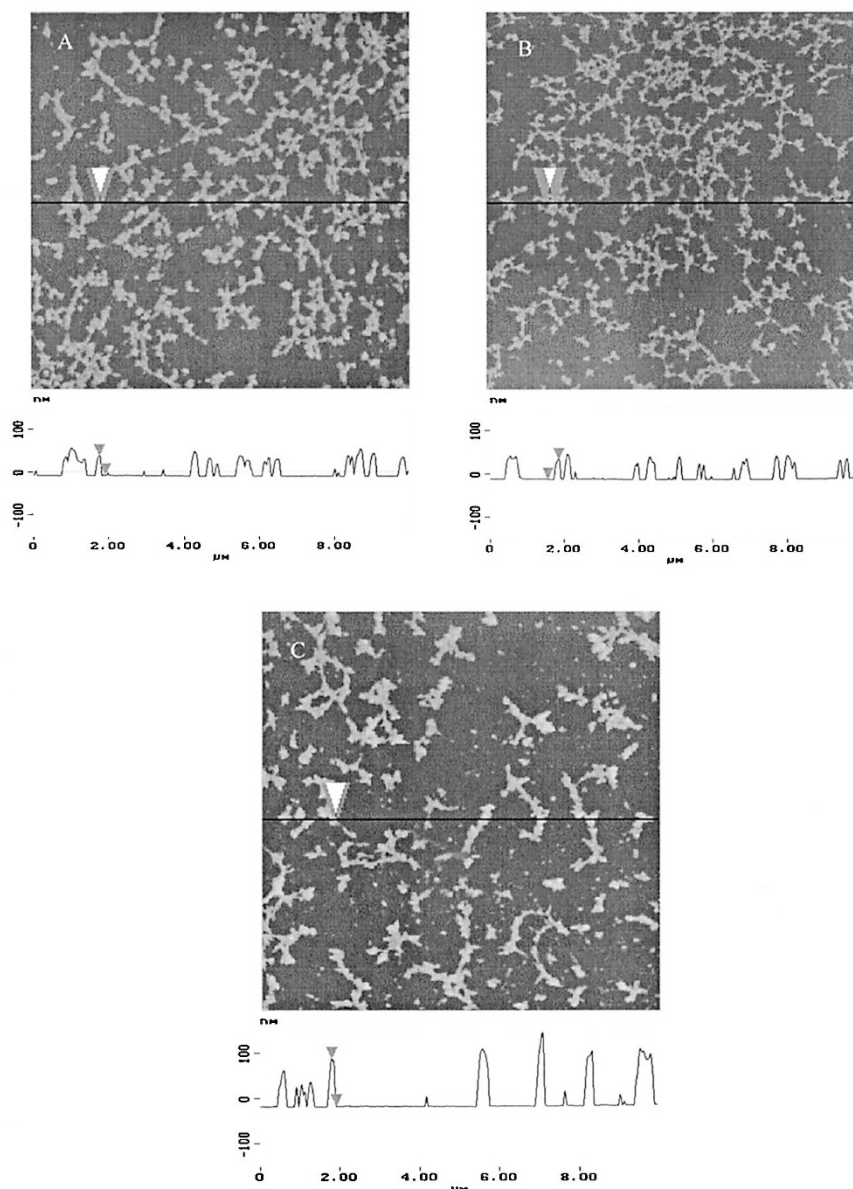
Surface topography measurements were performed on a nanoscope III Multi-Mode AFM of Digital Instruments in tapping mode. The images were obtained at room temperature in air. The solutions were spin-cast onto silicon wafer, mica and glass with the rotating speed of 3000 rpm. Silicon and glass were cleaned by acetone solvent then by hexane solvent prior to the



**Figure 1.** AFM images of aggregates of atactic PMMA spin-cast from acetone and chloroform solutions at a concentration of  $1 \text{ g L}^{-1}$  on silicon wafer. (A) acetone, (B) chloroform.

polymer deposition. Fresh mica layer was used.

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**Figure 2.** AFM images ( $10 \times 10 \mu\text{m}$ ,  $z = 300 \text{ nm}$ ) of atactic PMMA aggregates from acetone solution at a concentration of  $1 \text{ g L}^{-1}$  on the different substrates and the corresponding height at  $z$ -axis direction. (A) silicon wafer, (B) mica, and (C) glass.

## RESULTS AND DISCUSSION

The AFM image of atactic PMMA aggregates on silicon wafer from strong complexing solvent acetone was shown in Figure 1A. It indicates that the aggregates exhibit a dendritic structure. Its morphology is very similar with that of stereocomplex aggregates of the mixture of isotactic PMMA and syndiotactic PMMA with ratio  $i/s = 1/2$  which was observed by Grohens *et al.*<sup>8</sup> Aggregation on substrate was a non-equilibrium process, its morphology was related to many factors, such as solvent, substrate, temperature, concentration, and so on. We will mainly discuss the effect of solvent and substrate in detail here.

The AFM image of a-PMMA from non-complexing

solvent chloroform on silicon wafer was shown in Figure 1B. It is clear that the chloroform solution provided a homogeneously flattened morphology on the silicon wafer. Comparing the morphology of a-PMMA from chloroform solution with that from acetone solution, it is evident that the solvent nature is a predominant factor on the patterning of a-PMMA aggregates on a substrate. The state of a-PMMA in the solution affects its aggregation behavior on a substrate. Spevacek *et al.* and Borchard *et al.* have proved that stereocomplex was able to form in atactic PMMA solutions.<sup>3–5</sup> Studying with DSC and FT-IR,<sup>6,7</sup> we also found that a stereocomplex formed in atactic PMMA film from strong complexing acetone, while not in that from non-complexing chloroform. Stereocomplex in the film derived from the solution from which the film was cast.

Acting as a joint between molecular chains, stereocomplex leads to many molecular chains interaction and interpenetration each other in solution, so it is suppose that stereocomplex in atactic PMMA solution may play a role in the formation of dendritic morphology of a-PMMA aggregates on the substrate.

The AFM images of a-PMMA aggregates from acetone solvent on silicon wafer, mica and glass were shown in Figure 2. It can be seen that a-PMMA aggregates show a similar dendritic patterning on these substrates. The evident differences among them were the sizes of aggregates. It can be seen that the dendritic aggregates of a-PMMA spread extensively on silicon wafer and mica, while sparsely packed on glass. At the same time, the even height of the aggregates at *z*-axis direction on glass (103.8 nm or so) was about twice of that on silicon wafer (45.0 nm or so) and mica (44.3 nm or so). Dewetting effect on substrate would be responsible for the different sizes of PMMA aggregates on the substrates. Moreover, surface energy of three kinds of substrates was different. It leads to different interaction between PMMA and substrates, which would also at-

tribute to the different sizes of PMMA aggregates on the substrates.

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## REFERENCES

1. E. Schomaker and G. Challa, *Macromolecules*, **22**, 3337 (1989).
2. T. Serizawa, K. I. Hamada, T. Kitayama, N. Fujimoto, K. Hatada, and M. Akashi, *J. Am. Chem. Soc.*, **122**, 1891 (2000).
3. W. Borchard, M. Pyrlík, and G. Rehage, *Makromol. Chem.*, **145**, 169 (1971).
4. W. Borchard, G. Kalawrytinós, B. Mohadjer, M. Pyrlík, and G. Rehage, *Angew Makromol. Chem.*, **29/30**, 471 (1973).
5. J. Spevacek and I. Fernandez-Pierola, *Makromol. Chem.*, **188**, 851 (1987).
6. Q. Gu, R. Song, and D. Y. Shen, *Polym. Bull.*, **44**, 533 (2000).
7. J. J. Wang, J. Zhao, G. Gu, and D. Y. Shen, *Macromol. Rapid Commun.*, **22**, 948 (2001).
8. Y. Grohens, G. Castelein, P. Carriere, J. Spevacek, and J. Schultz, *Langmuir*, **17**, 86 (2001).